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Photonic Curing Enables Ultrarapid Processing of Highly Conducting β -Cu_{2- δ}Se Printed Thermoelectric Films in Less Than 10 ms

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highly conducting TE β -Cu_{2- δ}Se phase forms in the screen-printed Cu–Se-based film through ≤ 10 ms sintering using photonic-curing technology, minimizing the interfacial resistance. This enables overcoming the major challenges associated with printed thermoelectrics: (a) to obtain the desired phase, (b) to attain high electrical conductivity, and (c) to obtain flexibility. Furthermore, the photonic-curing process reduces the synthesis time of the TE β -Cu_{2- δ}Se film from several days to a few

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milliseconds. The sintered film exhibits a remarkably high electrical conductivity of ~3710 S cm⁻¹ with a TE power factor of ~100 μ W m⁻¹ K⁻². The fast processing and high conductivity of the film could also be potentially useful for different printed electronics applications.

1. INTRODUCTION

In general, different chemical and physical synthesis methods such as arc melting, solid-state reaction melt and growth, mechanical alloying, and hydrothermal synthesis are employed to prepare various thermoelectric (TE) materials.¹ Depending on the type of material, a suitable synthesis method is implemented. The synthesis processes are extremely important; they should be appropriate to get an expected phase and high TE performance. The melt and growth method is widely used to synthesize low-melting-temperature alloys, such as telluride/selenide chalcogenides and Zintl phases. In this process, metal elements with a stoichiometric ratio are kept in a vacuum-sealed quartz tube followed by heating at elevated temperatures for several hours to days so that all of the precursor elements interdiffuse to form the desired phases.² The melting points of the metal elements and annealing temperatures are generally determined from the phase diagram of the targeted alloys. The resulting consolidated ingots are ground into a powder and made into pellets using hot-pressing or spark plasma sintering (SPS) to prepare TE components. The mechanical alloying method has also been adopted to synthesize similar TE materials.^{3–5} Here, powder elements are mixed in a stoichiometric ratio and ground with a high-energy ball mill for several hours. The milling time and rotation speed of the jar containing balls and the ingredients depend on the formation energies of the alloys to be prepared. The resulting homogeneous milled powder samples are then consolidated into pellets using hot press or SPS. Sometimes, further heat treatment at high temperatures is required to acquire the

desirable phase. The Cu₂Se chalcogenide phase is one of the most interesting TE phases for its unique transport properties. The monoclinic α -Cu₂Se is the common phase at room temperature (RT) and transforms into the cubic disordered superionic β -Cu₂Se phase at elevated temperatures. In this phase, two separate sublattices, "Cu" and "Se", build the structure of Cu₂Se. A rigid crystalline symmetric framework is formed by the large Se atoms that help transfer the charge carriers, and the disordered Cu ions diffuse around the Se sublattices, resulting in a strong phonon scattering, facilitating a low lattice thermal conductivity. Therefore, the β -Cu₂Se phase exhibits a liquid-like behavior of the phonons and a crystal-like behavior of the charge carriers, a "phonon-liquid electron-crystal" behavior.⁶ Hence, β -Cu₂Se exhibits simultaneously high electrical conductivity and low thermal conductivity. Both the "melt and growth" and mechanical alloying synthesis processes are employed to prepare the bulk Cu₂Se phase, followed by grinding, pressing, and dicing to design Cu₂Se-based bulk TE components. The complete synthesis processes are reported to take up to 10 days.⁷⁻¹¹ Chemical synthesis methods have also been reported to

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Figure 1. V_P -dependent XRD patterns of the Cu–Se-based printed films at RT (a). Rietveld refinement results of the film for $V_P = 380 \text{ V}$ (b). β -Cu_{2- β}Se is identified as the main phase with a small fraction of unreacted Cu. Unit cell and lattice structure of β -Cu_{2- β}Se (c, d).

prepare Cu₂Se, which also involves multiple steps.¹² Apart from a complex and long synthesis process, the Cu₂Se-based bulk TE components reported so far are neither shapeconformal nor flexible. A flexible TE component would potentially be advantageous over its bulk counterparts as this allows wearable and complex geometry applications.^{13,14} Hence, efforts have been put forward to synthesize flexible Cu₂Se-based TE films using bulk or chemically prepared Cu₂Se particles.^{15,16} Recently, PEDOT:PSS/Cu₂Se-based composite TE films prepared by the vacuum filtration and pressing technique have been reported to exhibit good performance.^{17,18} However, unlike printing technology, the synthesis processes of these TE components are not low-cost and involve a set of complex processes.

Recently, we have reported Sb–Bi–Te/ β -Cu_{2- δ}Se TE films prepared by sintering in a vacuum oven. Nevertheless, there is a trade-off between high performance and good flexibility in the films.^{19–21} We have also reported high-performance Ag₂Sebased printed n-type TE films prepared by a similar sintering process.^{13,22,23} In this work, we have employed a fast photoniccuring technology on printed Cu–Se-based films to address the drawbacks associated with the traditional procedure to fabricate flexible β -Cu_{2- δ}Se-based TE films. We have used screen printing to fabricate TE films with high spatial resolution, and a very fast photonic-curing process is implemented to sinter the films. We have discovered that the TE β -Cu_{2- δ}Se phase is formed in less than 10 ms in the film, facilitating an ultrahigh electrical conductivity and mechanical flexibility without damaging the low-temperature substrates. The sintering time to form the $Cu_{2-\delta}Se$ phase reduces by 8 orders of magnitude from $\sim 10^6$ s in bulk to $\leq 10^{-2}$ s in the printed film.

2. EXPERIMENTAL METHODS

2.1. Materials. Copper powder (spheroidal) $(10-25 \ \mu m, 98\%, Sigma-Aldrich)$, Se powder (100 mesh, $\geq 99.5\%$ trace metal basis, Sigma-Aldrich), *N*-methyl-2-pyrrolidone (NMP) (anhydrous, 99.5%, Sigma-Aldrich), poly(vinylpyrrolidone) (PVP) (average $M_w \sim 40\ 000$, Sigma-Aldrich), and polyethylene naphthalate (PEN) (75 μ m, DuPont).

2.2. Synthesis of TE Inks and Films. The Cu-Se-based printable TE ink was prepared using a ball mill, Fritsch Planetary Mill PULVERISETTE 5 premium line. The Cu and Se elemental powders were mixed in a 2:1 atomic ratio in a PVP-NMP (6:94) solution. The blend was then kept in a N2 purged zirconia jar containing 10 mm zirconia balls followed by wet milling for 30 min at 200 rpm. The weight ratio of the balls to the mixture was 10:1. We printed the obtained Cu-Sebased ink on glass and flexible substrates using a semiautomated screen printer ROKUPRINT machine with a screen specification of $600 \times 300 90-40 \text{ y}/22^{\circ}$ Hitex. The printed films of the order of 10 μ m were dried on a hotplate after printing. After drying at 343 K, the printed films were flashsintered with 35 μ Pulses for 8–10 ms, varying the external input flashlamp voltage $(V_{\rm P})$ in the range of 300–400 V using a PulseForge 1200 (Novacentrix) photonic-curing machine. The temperatures of the top surface of the printed film, at the interface, and at the bottom of the substrate have been



Figure 2. Screen-printed sintered Cu₂Se film on the poly(ethylene terephthalate) (PET) substrate (a). Surface morphologies of the nonsintered film (b), sintered film with $V_P = 340$ V (c), and sintered film with $V_P = 380$ V (d) captured by a WLI 3D microscope. The microstructures and elemental maps of the nonsintered film (e, f) and the sintered film with $V_P \ge 340$ V (g, h).

simulated using the interactive numerical model SimPulse for PulseForge photonic-curing tools based on the heat transfer model. It can be seen that the top and interface temperatures reach 973 for $V_{\rm p}$ = 380 V where the substrate temperature remains near RT (cf. Figure S1). The film temperature decreases below 473 K within 50 ms.

2.3. Characterization Techniques. The phase and crystallographic analyses of the photonic-sintered printed films were conducted using X-ray diffraction (XRD) on a Bruker D8 diffractometer with a Lynxeye XE detector. The temperature-dependent transport parameters of the films were studied using a Hall measurement setup (Linseis HCS 10). The electrical conductivity is determined by the van der paw method with four contacts. A magnetic field is applied perpendicular to the film to produce a Hall voltage $(V_{\rm H})$. The Hall coefficient $(R_{\rm H})$ is determined from the $V_{\rm H}$, which is essential to determine the carrier concentration and mobility. The RT Seebeck coefficient α of the sintered film with $V_{\rm p}$ = 380 was measured using a custom-built setup. The working principle of the custom-built setup is given in Supporting Information Note 2 of the previous report.¹⁴ The thicknesses and surface morphologies of the printed films were studied by a Bruker 3D microscope based on white-light interferometry (WLI). Microstructural and elemental analyses of the sintered films were conducted using an FEI Quanta 650 environmental scanning electron microscope (ESEM) equipped with a Schottky field emitter and an SSD detector operating with 5 and 15 kV.

3. RESULTS AND DISCUSSION

The crystallographic and phase analyses of the nonsintered and sintered films were extensively studied using the X-ray diffraction (XRD) technique (cf. Figure 1). XRD patterns of the sintered films for different $V_{\rm p}$ from 300 to 400 V were collected while keeping the sintering time constant at 10 ms. The XRD pattern of the nonsintered printed film corresponds to the two unreacted Cu and Se. The β -Cu_{2- δ}Se phase starts to grow when $V_{\rm p}$ reaches 320 V and is found to be fully developed for $V_{\rm p} \ge 380$ V (cf. Figure 1a). To get insight into the crystallographic structure of the β -Cu_{2- δ}Se phase, Rietveld refinement of the XRD pattern of the sintered film for $V_{\rm p} = 380$ V was performed (cf. Figure 1b). The results indicate that the XRD pattern corresponds to a main cubic β -Cu_{2- δ}Se phase

with space group $Fm\overline{3}m$ and a fraction of unreacted Cu. The nonstoichiometry " δ " is estimated to be up to 0.1. Most probably, the δ is responsible for the RT β -Cu_{2- δ}Se phase as it is also reported that $\delta = 0.03$ can enable a phase transformation of the conventional α -Cu_{2- δ}Se phase to the cubic β -Cu_{2- δ}Se phase. The lattice parameter of the unit cell of the β -Cu_{2- δ}Se phase is estimated to be a = 5.7(6) Å. The Se atoms in the β -Cu_{2- δ}Se crystal form a rigid face-centered cubic cell occupying the Wyckoff position 4a (0, 0, 0), and the Cu atoms occupy two different Wyckoff positions 8c (1/4, 1/4, 1/4) and 32f (x, x, x).

The detailed microstructural and morphological analyses of the printed sintered and nonsintered films are included in Figure 2. The screen printability of the Cu–Se-based film was checked using the ROKUPRINT screen-printing machine (cf. Figure 2a). Macroscopic morphologies of the printed Cu_2Se films for sintering and nonsintering conditions were studied using three-dimensional (3D) microscopy; see Figure 2b-d. The morphology of the nonsintered film shows segregated island-like structures of the Cu-Se material. SEM images of the nonsintered and sintered films also show that the film was compacted after sintering with $V_{\rm P}$ = 380 V and becomes denser (cf. Figure 2e,g). The elemental mapping of the printed films indicates that the Cu and Se elements were segregated in the nonsintered film and they almost fully reacted to form the β - Cu_2Se phase in the sintered film. The b/w regions in the elemental mappings in Figure 2h correspond to the potholes created due to the expulsion of the organic constituents from the film during the sintering process. A sufficient number of data from potholes did not reach the energy-dispersive X-ray analysis (EDX) detector.

The remnant of organic binder PVP could be present in the films; however, it constitutes only 1.6 wt % (<10 vol %) of the films. After sintering, it decomposes releasing <3 vol % of carbon in the film, which is far below the percolation threshold to influence the transport properties.²⁴ The mechanical flexibility of a 15 mm sintered film for $V_{\rm p}$ = 380 V has been checked by a semicircular bending test multiple times. The normalized resistance of the film was found to be 1.5 after 10 bending cycles (cf. Figure S2).

3.1. Thermotransport Properties of Photonic-Cured Films. The temperature-dependent transport properties were studied for $V_P \leq 380$ V (cf. Figure 3). The mechanical



Figure 3. Variation of electrical conductivity σ (a), Hall carrier concentration $p_{\rm H}$ (b), Hall coefficient $R_{\rm H}$ (c), and Hall carrier mobility $\mu_{\rm H}$ (d) of the Cu–Se-based printed film with temperature for different $V_{\rm P}$, $320 \le x \le 380$.



Figure 4. Variation of the transport parameters σ , $p_{\rm H}$, and $\mu_{\rm H}$ with the input flashlamp voltage $V_{\rm P}$ (a). Electric conductivity is modeled, and the line through the data points is a fit (b). Temperature-dependent α and power factor of the photonic-cured film for $V_{\rm P}$ = 380 V (c). Semicircular bending test of a 15 mm sintered film for $V_{\rm P}$ = 380 V to check its mechanical flexibility (d).

flexibility and the electrical conductivities σ of the printed film deteriorate for $V_{\rm P} > 380$ V. The nonsintered film is found to be insulating and becomes highly conductive after sintering. All of the films show p-type conduction, and the σ increases with increasing $V_{\rm P}$, altering the transport properties and the nature of the films for $V_{\rm P} > 340$ V (cf. Figure 3a). The negative value of ($R_{\rm H}$) at T > 323 K for the film with $V_{\rm P} = 320$ V indicates alteration of the conduction nature, from p-type to n-type, as the β -Cu₂Se phase is not formed. Although the Hall carrier concentration ($p_{\rm H}$) decreases with increasing $V_{\rm P}$, the σ increases because of significant enhancement of the carrier mobility ($\mu_{\rm H}$) (cf. Figure 3b,d). The films for $V_{\rm P} \ge 360$ V show a metallic-like nature, consistent with the previously reported transport phenomena of the pristine β -Cu₂Se-based film.²⁰

A surprisingly high $\sigma \sim 3710$ S cm⁻¹ is achieved at RT in the flexible printed film for $V_p = 380$ V. The σ value is much higher than those of most reported Cu₂Se-based bulk materials⁶⁻⁹ because of leftover unreacted Cu elements in the film. The electrical conductivity σ and Hall mobility μ_H of the printed film increase with increasing the flashlamp voltage V_p , which is directly proportional to the sintering temperature of the film. The insulating organic ingredients in the printed film start to be removed with increasing V_p . The elemental Cu and Se then react to form β -Cu₂Se with further increase of V_p , enhancing the σ of the sintered film (Figure 4). At first, the charge carrier concentration p_H of the film increases with increasing V_p for \leq 340 V due to the removal of the insulating organic constituents, leaving partially unreacted Cu and Se in the printed film, as shown in Figure 1a.

The amount of the unreacted elements decreases with increasing $V_{\rm P}$ for $V_{\rm P}$ > 340 V resulting in the decrease of $p_{\rm H}$ in the film. As the $p_{\rm H}$ of the Cu element (~8.55 × 10²² cm⁻³) is one order of magnitude higher than that for the β -Cu₂Se phase (<5 × 10²¹ cm⁻³), with decreasing unreacted Cu, the overall σ decreases for $V_{\rm P}$ > 340 V. The temperature-dependent electrical transport of the film for $V_{\rm P}$ = 380 V is modeled using a metal-semiconducting transport equation.²⁵ The film is found to be metallic in nature (cf. Figure 4b). The RT σ of the sintered film stored in the air atmosphere for $V_{\rm p}$ = 380 V was measured after many weeks and it is found to be decreased slightly. Storing in an N2 or inert gas environment could prevent decreasing the conductivity. Due to the presence of unreacted Cu elements, the Seebeck coefficient (α) is also found to be lower. A positive $\alpha \sim 16 \ \mu V \ K^{-1}$ and a TE power factor of ~95 μ W m⁻¹ K⁻² are achieved in the film at RT (cf. Figure 4c). The power factor value is twice as high as the previously reported vacuum-sintered β -Cu₂Se film.²⁰ Unfortunately, we could not determine the thermal conductivity of the film due to the nature of the synthesis process and film specification. However, the thermal conductivity value could be higher compared to the β -Cu₂Se film, resulting in lower ZT due to its high conductivity. In addition to TE applications, the highly conductive p-type β -Cu₂Se film could be potentially employed for printed sensors and optoelectronic applications.^{26–28}

4. CONCLUSIONS

A long sintering process at elevated temperatures is one of the most important steps to synthesis a TE phase. However, in printed thermoelectrics, low-temperature substrates with printed precursor materials do not withstand the high-temperature sintering process to form a TE phase. This work employs photonic-curing technology to sinter the printed Cu–

Se-based material without damaging the flexible low-temperature substrates. The TE β -Cu₂Se phase is formed within 10 ms through the photonic curing in the printed film. The obtained sintered flexible film exhibits a remarkably high electrical conductivity of 3710 S cm⁻¹ with a TE power factor of 95 μ W m⁻¹ K⁻² at RT.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge at https://pubs.acs.org/doi/10.1021/acsomega.2c00412.

Synthesis of TE inks and films (Supporting Note 1: synthesis methods), numerical model SimPulse for PulseForge photonic-curing tools to determine the film temperature (Figure S1), characterization of the photonic-cured films (Supporting Note 2: characterization techniques), semicircular bending test of the film (Figure S2), and recently reported RT power factor of solution-processed Cu2Se-based flexible films (Table S1) (PDF)

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Notes

The authors declare no competing financial interest.

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